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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/602,192	06/24/2003	Markus Nopper	2000.106500 1016		
23720	7590 10/29/2004	EXAMINER			
	MORGAN & AMEI	EVERHART	EVERHART, CARIDAD		
10333 RICHMOND, SUITE 1100 HOUSTON, TX 77042			ART UNIT PAPE		
,			2825		

DATE MAILED: 10/29/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

· · · · · · · · · · · · · · · · · · ·			Application No.		Applicant(s)		
Office Action Summary		10/602,19	2	NOPPER ET AL.			
		Examiner		Art Unit			
		Caridad M.		2825	ar a		
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status							
1)[	Responsive to communication(s) filed on						
2a) <u></u> □	This action is <b>FINAL</b> . 2b)⊠ This action is non-final.						
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims							
5)□ 6)⊠ 7)⊠	<ul> <li>✓ Claim(s) 1-28 is/are pending in the application.</li> <li>4a) Of the above claim(s) is/are withdrawn from consideration.</li> <li>☐ Claim(s) is/are allowed.</li> <li>✓ Claim(s) 1-4,13-19,24 and 26-28 is/are rejected.</li> <li>✓ Claim(s) 5-12,20-23 and 25 is/are objected to.</li> <li>☐ Claim(s) are subject to restriction and/or election requirement.</li> </ul>						
Applicati	ion Papers						
9)[	The specification is objected to by the Exam	niner.					
10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.							
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority u	ınder 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).  a) ■ All b) ■ Some * c) ■ None of:  1. ■ Certified copies of the priority documents have been received.  2. ■ Certified copies of the priority documents have been received in Application No. ■  3. ■ Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).  * See the attached detailed Office action for a list of the certified copies not received.							
Attachmen							
1) Notice of References Cited (PTO-892)  4) Interview Summary (PTO-413)  Paper No(s)/Mail Date							
3) 🛛 Infor	e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB, r No(s)/Mail Date <u>8-13-04,5-6-04</u> .	3/08)	5) Notice of Informal Po		O-152)		

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## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

The factual inquiries set forth in *Graham* v. *John Deere Co.*, 383 U.S. 1, 148 USPQ 459 (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:

- 1. Determining the scope and contents of the prior art.
- 2. Ascertaining the differences between the prior art and the claims at issue.
- 3. Resolving the level of ordinary skill in the pertinent art.
- 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

Claims 1-4,13-19, 24, and 26-28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Matsuda, et al. (US 6,403,481B1).

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Matsuda, et al disclose the steps of depositing over a patterned dielectric layer(shown in Fig. 7A) a first material layer which is a TaN film with a palladium film discontinuously deposited(col. 5, lines 38-44 and col. 6, lines 22-27). The sputtering is known to be a method which is performed from a gaseous atmosphere. Both films are sputtered(col. 5, lines 38-44 and col. 6, lines 23-27). Then a copper film is electrolessly plated (col. 5, lines 57-65) from a plating solution. The target is a palladium target(col. 6, lines 26-28), which satisfies the limitation that the palladium is uniformly distributed in the target. The palladium has a catalytic function(col. 6, lines 48-50). The structure is also taught(Fig. 7A) which results from the process steps.

In the embodiment in which copper is electrolessly plated, copper is the sputtered film rather than palladium, which is used in the embodiment in which silver is electrolessly plated. The barrier may be deposited by CVD(col. 6, lines 60-65).

It would have been obvious to one of ordinary skill in the art at the time of the invention to have used palladium as the sputtered film in the copper electroless plating embodiment because Matsuda et al dilsclose that the embodiments are only representative and modifications can be made, and other embodiments such as in col. 8, lines 4-14 suggest that other metals can be substituted for the various layers. The same or different metals may be used for the sputtered and the electrolessly plated metal, such that the electrolessly plated metal is more preferentially formed on the sputtered metal than on the first film, which in the embodiment cited above is the TaN film(claims 2 and 3). One of ordinary skill in the art would also have been motivated to

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have used the palladium in the copper embodiment because of the disclosed catalytic activity disclosed by Matsuda et al.

## Allowable Subject Matter

Claims 5,6-12,20-23, and 25 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The prior art of record does not disclose or suggest all of the limitations of the objected-to claims. For example, although Matsuda et al teaches the barrier layer deposited by CVD, Matsuda et al does not disclose "depositon of said barrier layer a precursor containing said catalytic material is present" nor the limitations of the other objected-to claims.

The prior art of record not relied upon is considered relevant to applicant's disclosure.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Caridad M. Everhart whose telephone number is 571-272-1892. The examiner can normally be reached on Monday through Fridays 7:30-4:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew S. Smith can be reached on 571-272-1907. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

O. Kuchar ONTICAD EVERHALI POLLARY EXAMENTED

C. Everhart 10-20-2004